

## **AMENDMENTS TO THE CLAIMS**

1. (Currently Amended) A color filter substrate comprising:

a transparent substrate; and

color filters of three colors with a bored part provided at every pixel on said transparent substrate, said color filters of three colors neighboring to each other in one direction being connected to each other, a thin film transistor being opposed to said bored part, and data lines being aligned along said one direction.

2. (Previously Presented) The color filter substrate according to claim 1, further comprising color filters formed in said bored parts with a material identical to any one of said color filters of three colors.

3. (Currently Amended) The color filter substrate according to claim 1, further comprising a grid-like black matrix including openings formed for all the pixels, and a light-shielding film formed in said bored part with a material ~~same as~~ identical to that of said black matrix.

4. (Withdrawn) A manufacturing method of a color filter substrate comprising the steps of:

forming a black matrix on a transparent substrate;

forming first color filters with a first bored part in all the pixels displaying a first color on said black matrix, a thin film transistor provided at every pixel displaying said first color being to oppose to said first bored part;

forming second color filters with a second bored part in all the pixels displaying a second color on said black matrix, a thin film transistor provided at every pixel displaying said second color being to oppose to said second bored part; and

forming third color filters with a third bored part in all the pixels displaying a third color on said black matrix, a thin film transistor provided at every pixel displaying said third color being oppose to said third bored part.

5. (Withdrawn) A manufacturing method of a color filter substrate comprising the steps of:

forming a black matrix on a transparent substrate;

forming first color filters in all the pixels displaying a first color, in a part of all the pixels displaying a second color, and in a part of all the pixels displaying a third color on said black matrix, a thin film transistor provided at every pixel displaying said second color being to oppose to said part of said pixels displaying said second color, and a thin film transistor provided at every pixel displaying said third color being to oppose to said part of said pixels displaying said third color;

forming second color filters with a second bored part in all the pixels displaying said second color on said black matrix, said thin film transistor provided at every pixel displaying said second color being to oppose to said second bored part; and

forming third color filters with a third bored part in all the pixels displaying a third color on said black matrix, said thin film transistor provided at every pixel displaying said third color being oppose to said third bored part.

6. (Original) An active matrix type liquid crystal display comprising a color filter substrate according to claim 1.

7. (Original) An active matrix type liquid crystal display comprising a color filter substrate according to claim 2.

8. (Original) An active matrix type liquid crystal display comprising a color filter substrate according to claim 3.

9. (Withdrawn) A manufacturing method of an active matrix type liquid crystal display comprising the steps of:

manufacturing a color filter substrate based on a method described in claim 4; and  
adhering a substrate with said thin film transistors and said color filter substrate.

10. (Withdrawn) A manufacturing method of an active matrix type liquid crystal display comprising the steps of:

manufacturing a color filter substrate based on a method described in claim 5; and  
adhering a substrate with said thin film transistors and said color filter substrate.